



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of: Kwan-Yong LIM, et al.

Serial No.: 10/616,302 Group Art Unit: 2815

Filed: July 10, 2003 Examiner: Jackson Jr., Jerome

For: STACK GATE ELECTRODE SUPPRESSED WITH INTERFACE-REACTION AND

METHOD FOR FABRICATING SEMICONDUCTOR DEVICE HAVING THE

SAME

RESPONSE TO RESTRICTION REQUIREMENT

Honorable Commissioner for Patent P.O. Box 1450 Alexandria, VA 22313-1450

May 17, 2004

Sir:

In response to the Request for Restriction mailed April 20, 2004 (Paper No. 041404), Applicant elects Group II, claims 6-10, drawn to a process, classified in class 438, subclass 15+, with traverse.

Applicant respectfully traverses the restriction requirement. The claims of Group I (Claims 1-5) drawn to a product and the claims of Group II (Claims 6-10) drawn to a process are closely related to each other and define a single invention. The product defined in claims 1-5 is manufactured by the process of claims 6-10, and thus, claims 1-10 define a single inventive concept. Further, Applicant respectfully submits that it would not be unduly burdensome for the Examiner to examine the claims of both groups. Applicant respectfully requests that claims 1-10 be examined.

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An early Office Action on the merits is respectfully requested.

If a Petition for Extension of Time is necessary and the petition and/or payment of the fee(s) is not enclosed, this will act as a petition to extend the time for response and an authorization to charge the necessary fee(s) under 37 CFR 1.17(a)-(d) to Deposit Account 06-1358.

Respectfully submitted,

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